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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

: **Confirmation No. 8980**

Katsumi OOMORI et al.

: Docket No. 2002_0091

Serial No. 10/059,236

: Group Art Unit 1752

Filed January 31, 2002

: Examiner S. Lee

POSITIVE-WORKING CHEMICAL-
AMPLIFICATION PHOTORESIST
COMPOSITION

RECEIVED

DEC 09 2003

TC 1700

RESPONSE

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

In response to the Official Action dated September 8, 2003, please amend the present application as follows: